



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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 GROUP 170C

Applicant : Nicholas F. Borrelli, Thomas P. Seward III, and
 Charlene M. Smith
 Appl. No. : 10/039,507
 Filed : October 26, 2001
 For : SILICA WITH LOW COMPACTION UNDER HIGH
 ENERGY IRRADIATION
 Examiner : M. Colaianni
 Group : 1731

CHANGE OF CORRESPONDENCE ADDRESS

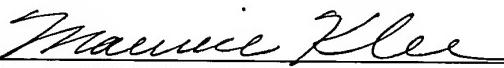
The Zip Code for the correspondence address for the above application has been changed by the U.S. Postal Service from 06430 to 06824.

Please update the Patent Office's records to reflect the new Zip Code. Specifically, the correspondence address should be changed to:

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Respectfully submitted,

Date: 7/14/03


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